

PART ONE: General description

<input type="text" value="Lithography2"/> <i>Process name</i>	<input type="text" value="UL3_002"/> <i>Process Code</i>	<input type="text" value="04/24/00"/> <i>Last Update</i>
<input type="text" value="Udo Lang"/> <i>Author</i>	<input type="text" value="lang@ee"/> <i>Contact Information (Email)</i>	
<input type="text" value="AZ 4620, single layer , thickness - 12 mic"/> <i>General description of process</i>		

PART TWO: Details

Cleaning

<input checked="" type="checkbox"/> Nano-strip	<input type="text" value="10"/> <i>Time (min)</i>	<input type="checkbox"/> BOE	<input type="text"/> <i>Time (min)</i>
--	--	------------------------------	---

Rinse and Dry

Resist Coating

<input type="checkbox"/> P-10 <i>Primer</i>	<input type="text"/> <i>Speed1 (RPM)</i>	<input type="text"/> <i>Time(sec)</i>	<input type="text"/> <i>Speed2 (RPM)</i>	<input type="text"/> <i>Time(sec)</i>
<input checked="" type="checkbox"/> HMDS				
<input checked="" type="checkbox"/> AZ 4620 <i>Resist</i>	<input type="text" value="500"/> <i>Speed1 (RPM)</i>	<input type="text" value="5"/> <i>Time(sec)</i>	<input type="text" value="1500"/> <i>Speed2 (RPM)</i>	<input type="text" value="40"/> <i>Time(sec)</i>
<input checked="" type="checkbox"/> PreBake	<input type="text" value="Oven"/> <i>Developer</i>	<input type="text" value="80"/> <i>T (°C)</i>	<input type="text" value="30"/> <i>Time(min)</i>	
<input checked="" type="checkbox"/> Exposure	<input aligner"="" type="text" value="3"/>		<input type="text" value="40"/> <i>Time(sec)</i>	
<input checked="" type="checkbox"/> Develop	<input type="text" value="AZ351:H2O (1:4)"/> <i>Developer</i>		<input type="text" value="120"/> <i>Time(sec)</i>	
<input checked="" type="checkbox"/> PostBake	<input type="text" value="Oven"/> <i>Developer</i>	<input type="text" value="120"/> <i>T (°C)</i>	<input type="text" value="30"/> <i>Time(min)</i>	

Rinse and Dry

PART THREE: General Comments

4" aligner - 45 sec exposure.

